AMENDMENTS TO THE CLAIMS

This listing of claims replaces all prior versions of claims in the application.

**Listing of Claims** 

Claim 1 (currently amended): A composition for forming a transparent conducting film,

the composition comprising a water-soluble indium compound, a halogen-containing water-

soluble organotin compound and a water-soluble organic high molecular weight compound.

Claim 2 (original): The composition according to claim 1, wherein the halogen-

containing water-soluble organotin compound is one in which a first endothermic peak

temperature in a differential thermal analysis curve is 75 °C or higher.

Claim 3 (original): The composition according to claim 1, wherein the difference between

the first endothermic peak temperature of the water-soluble indium compound and the first

endothermic peak temperature of the halogen-containing water-soluble organotin compound in

the differential thermal analysis curve is 100 °C or less.

Claim 4 (original): A solution for forming a transparent conducting film, the solution

having the composition of claim 1, 2 or 3 dissolved in water or a solvent comprising water and

an organic solvent.

Claim 5 (currently amended): The solution according to claim 4, wherein water is present

in a ratio of 10 to 100 wt. % based on the total solvent, and the water-soluble organic high

molecular weight compound is present in a ratio of [[0.03]] 1 to 10 wt. % based on the total

solution.

Claim 6 (original): The solution according to claim 4 which has a surface tension of 20 to

70 mN/m and a viscosity of 20 mPa·s or less.

Claim 7 (original): A method for forming a transparent conducting film, which comprises

the steps of

(1) applying the solution of claim 4 onto a substrate, and

(2) firing the coating film.

Claim 8 (original): The method according to claim 7, wherein the firing is carried out in

an atmosphere which has higher partial oxygen pressure than air in step (2).

Claim 9 (original): The method according to claim 7, which further comprises a step of

subjecting the film obtained in step (2) to a reducing heat treatment.

Claim 10 (currently amended): The method according to claim 7, wherein the solution of

step (1) has water in a ratio of 10 to 100 wt. % based on the total solvent, and has the water-

soluble organic high molecular weight compound in a ratio of 0.03 to 10 wt. % based on the total

solution.

Claim 11 (original): The method according to claim 7, wherein the solution of step (1)

has a surface tension of 20 to 70 mN/m and a viscosity of 20 mPa·s or less.

Claim 12 (new): The composition according to claim 1, wherein the halogen-containing

water-soluble organotin compound is at least one compound selected from the group consisting

of compounds represented by the formula (1)

 $R_n Sn X_{4-n}$  (1)

wherein R is an alkyl group having 1 to 3 carbon atoms, X is a halogen atom and n is an

integer from 1 to 3.

Claim 13 (new): The composition according to claim 1, wherein the halogen-containing

water-soluble organotin compound is dimethyltin dichloride.

Claim 14 (new): The composition according to claim 1, wherein the water-soluble indium

compound is at least one compound selected from the group consisting of indium chloride,

indium nitrate, indium perchlorate, and indium sulfate.

Claim 15 (new): The composition according to claim 1, wherein the halogen-containing

water-soluble organotin compound is dimethyltin dichloride and water-soluble indium compound

is indium chloride trihydrate or indium nitrate trihydrate.

Claim 16 (new): The composition according to claim 1, wherein the water-soluble

organic high molecular weight compound is at least one compound selected from the group

consisting of polyvinyl alcohol, polyethylene glycol and polyvinyl pyrrolidone.